

AMENDMENTS TO THE CLAIMS

The following listing of claims will replace all prior versions and listings of claims in the application.

LISTING OF CLAIMS

1. (Currently Amended) A color filter substrate comprising:
a substrate;
a first colored layer disposed in a first region of the substrate; and
a second colored layer disposed in a second region of the substrate;
wherein the first colored layer and the second colored layer are disposed adjacent to each other and have the same hue as each other, one of the first colored layer and the second colored layer being darker than the other;
a surface of the second region where the second colored layer is disposed is higher than a surface of the first region where the first colored layer is disposed, and
a step difference plane is provided between the first region and the second region; and
an interface portion between the first colored layer and the second colored layer is disposed in a region toward the second region from the bottom portion of the step difference plane.
2. (Original) A color filter substrate according to Claim 1,
wherein a protrusion is provided on a surface of the interface portion by overlapping the first colored layer and the second colored layer, and the protrusion is disposed in a region toward the second region from the bottom portion of the step difference plane.

3. (Original) A color filter substrate according to Claim 1,
wherein the step difference plane is inclined and at least a portion of the interface portion is disposed in a region overlapping the step difference plane in plan view.
4. (Currently Amended) A color filter substrate according to Claim 1,
further comprising a light transmission portion disposed ~~which enables light to be transmitted is provided~~ in the first region[[,]] and a light reflection portion having ~~where~~ a light reflection layer ~~[[is]] disposed is provided~~ in the second region.
5. (Original) A color filter substrate according to Claim 4,
wherein the light reflection portion includes the interface portion.
6. (Currently Amended) A color filter substrate according to Claim 1,
further comprising an electrode integrally formed on a surface extending from the first region ~~via the step difference plane~~ to the second region by way of the step difference plane.
7. (Currently Amended) A method of manufacturing a color filter substrate comprising:
~~a first coloring step of~~ disposing a first colored layer in a first region;
~~a second coloring step of~~ disposing a second colored layer in a second region, the first and second colored layers having the same hue as each other, one of the first colored layer and the second layer being darker than the other; and
~~a step difference forming step of~~ forming a step difference where a surface of the second region where the second colored layer is disposed is formed to be higher

than a surface of the first region where the first colored layer is disposed via a step difference plane between the first region and the second region;

wherein, in the step of forming the step ~~difference-forming step~~, the bottom portion of the step difference plane is formed in a region toward the first colored layer from ~~the~~ an interface portion between the first colored layer and the second colored layer.

8. (Currently Amended) A method of manufacturing a color filter substrate according to Claim 7,

~~wherein, in the first and second coloring steps,~~ the first colored layer and the second colored layer are formed to overlap each other on the interface portion.

9. (Currently Amended) A method of manufacturing a color filter substrate according to Claim 7, wherein, ~~in the step difference-forming step,~~ the step difference plane is formed as an inclined plane in a region overlapping at least a portion of the interface portion in plan view.

10. (Currently Amended) A method of manufacturing a color filter substrate according to Claim 7,

further comprising ~~a step of forming a light reflection layer~~ having, ~~wherein the light reflection layer has~~ an opening in the first region,

~~wherein the light reflection layer~~ covering ~~is formed to cover~~ the interface portion in plan view.

11. (Original) An electro-optical device comprising:
an electro-optical material;
an electric field applying means for applying an electric field to the electro-optical material; and
a color filter substrate according to Claim 1.

12. (Currently Amended) An electro-optical device according to Claim 11,
wherein the electro-optical material is a liquid crystal layer having a first thickness in the first region and a second thickness in the second region that is less than the first thickness, a difference between the first thickness and the second thickness, and a liquid crystal layer in the first region is configured to be thicker than a liquid crystal layer in the second region, corresponding to the height difference between the first region and the second region ~~in the color filter substrate.~~

13. (Currently Amended) A method of manufacturing an electro-optical device comprising:

~~a first coloring step of~~ disposing a first colored layer in a first region on a substrate to be arranged along an electro-optical material;

~~a second coloring step of~~ disposing a second colored layer in a second region on ~~[[a]]~~ the substrate to be arranged along ~~an~~ the electro-optical material, the first and second colored layers having the same hue as each other, one of the first colored layer and the second colored layer being darker than the other; and

~~a step difference forming step~~ forming a step difference where a surface of the second region where the second colored layer is disposed is formed to be higher than a surface of the first region where the first colored layer is disposed via a step difference plane between the first region and the second region;

wherein, in the step of forming the step ~~difference-forming step~~, the bottom portion of the step difference plane is formed in a region toward the first colored layer from ~~the~~ an interface portion between the first colored layer and the second colored layer.

14. (Currently Amended) A method of manufacturing an electro-optical device according to Claim 13,

wherein, ~~in the first and second coloring steps~~, the first colored layer and the second colored layer are formed to overlap each other in the interface portion.

15. (Currently Amended) An electronic apparatus comprising an electro-optical device according to Claim 11[[,]] and a controller ~~control means~~ for controlling the electric field ~~applying means of the electro-optical device~~.